



High-Precision Diffractive Optics for X-ray and EUV applications

Inprentus designs, manufactures and sells blazed diffraction gratings for x-ray and EUV applications for synchrotron, free electron laser, as well as high powered laser applications requiring chirped pulsed amplification as well as a variety of spectrometer and monochromator applications.

Blazed Diffraction Gratings

- Custom VLS gratings for spectrometers and monochromators
- FEL gratings for self-seeding and photon diagnostics
- CPA Gratings for high powered lasers
- Master Gratings for OES systems and other spectroscopies
- Echelle gratings for laser applications

Key Features

- Blaze angles from 0.1° to 80°
- VLS - Variable Line Spaced gratings
- Ruling on curved substrates - concave, convex, toroidal
- Resolving power above 100,000
- High damage threshold
- Overcoating available
- Dimensions up to 500 x 200mm
- Line densities from 50 to 6000 l/mm
- Gold (Au) coated ruling surface with silicon or fused silica substrates
- Simulation services and grating design optimization services



Contact us with for your next diffraction grating project

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